

Subscriber access provided by Grand Valley State | University

Chemical Pressure-Driven Enhancement of the Hydrogen Evolving Activity of NiP from Nonmetal Surface Doping Interpreted via Machine Learning

Robert B. Wexler, John Mark P. Martirez, and Andrew M. Rappe

J. Am. Chem. Soc., Just Accepted Manuscript • DOI: 10.1021/jacs.8b00947 • Publication Date (Web): 19 Mar 2018

Downloaded from http://pubs.acs.org on March 20, 2018

Just Accepted

"Just Accepted" manuscripts have been peer-reviewed and accepted for publication. They are posted online prior to technical editing, formatting for publication and author proofing. The American Chemical Society provides "Just Accepted" as a service to the research community to expedite the dissemination of scientific material as soon as possible after acceptance. "Just Accepted" manuscripts appear in full in PDF format accompanied by an HTML abstract. "Just Accepted" manuscripts have been fully peer reviewed, but should not be considered the official version of record. They are citable by the Digital Object Identifier (DOI®). "Just Accepted" is an optional service offered to authors. Therefore, the "Just Accepted" Web site may not include all articles that will be published in the journal. After a manuscript is technically edited and formatted, it will be removed from the "Just Accepted" Web site and published as an ASAP article. Note that technical editing may introduce minor changes to the manuscript text and/or graphics which could affect content, and all legal disclaimers and ethical guidelines that apply to the journal pertain. ACS cannot be held responsible for errors or consequences arising from the use of information contained in these "Just Accepted" manuscripts.



Chemical Pressure-Driven Enhancement of the Hydrogen Evolving Activity of Ni₂P from Nonmetal Surface Doping Interpreted via Machine Learning

Robert B. Wexler,[†] John Mark P. Martirez,[‡] and Andrew M. Rappe*,[†]

†Department of Chemistry, University of Pennsylvania, Philadelphia, PA 19104-6323, USA ‡Department of Mechanical and Aerospace Engineering, Princeton University, Princeton, NJ 08544, USA

E-mail: rappe@sas.upenn.edu

Abstract

The activity of Ni₂P catalysts for the hydrogen evolution reaction (HER) is currently limited by strong H adsorption at the Ni₃-hollow site. We investigate the effect of surface nonmetal doping on the HER activity of the Ni₃P₂ termination of Ni₂P(0001), which is stable at modest electrochemical conditions. Using density functional theory (DFT) calculations, we find that both 2p nonmetals and heavier chalcogens provide nearly thermoneutral H adsorption at moderate surface doping concentrations. We also find, however, that only chalcogen substitution for surface P is exergonic. For intermediate surface concentrations of S, the free energy of H adsorption at the Ni₃-hollow site is -0.11 eV, which is significantly more thermoneutral than the undoped surface (-0.45 eV). We use the regularized random forest machine learning algorithm to discover the relative importance of structure and charge descriptors, extracted from

the DFT calculations, in determining the HER activity of Ni₂P(0001) under different doping concentrations. We discover that the Ni-Ni bond length is the most important descriptor of HER activity, which suggests that the nonmetal dopants induce a chemical pressure-like effect on the Ni₃-hollow site, changing its reactivity through compression and expansion.

Introduction

The discovery of highly active, noble-metal-free catalysts for the hydrogen evolution reaction (HER) is crucial for the development of economical water-splitting fuel storage technologies. There have been many candidates proposed in the last two decades, most notably $\text{MoS}_2^{1,2}$ and Ni_2P .^{3,4} Recently, we found that the bulk-like Ni_3P_2 termination of the $\text{Ni}_2\text{P}(0001)$ surface, which is stable at modest electrochemical conditions, *i.e.* reducing potentials greater than -0.21 V vs. the standard hydrogen electrode (SHE) and pH=0, is not catalytically-active because the Ni_3 -hollow site binds H too strongly ($\Delta G_{\rm H}=-0.45~\text{eV}$).⁵ Upon the application of -0.21 V vs. SHE, however, the surface becomes enriched with P adatoms, which provide nearly thermoneutral H adsorption and consequently catalytic activity toward the HER.⁵

In order to overcome the inactivity of the Ni₃-hollow site, attempts have been made to tune the HER activity of Ni₂P by doping with different transition metals such as Co,^{6–8} Fe,⁹ Mn,¹⁰ and Mo.¹¹ There have been no attempts, however, to dope Ni₂P with nonmetals, despite the host of stable binary Ni-nonmetal compounds that exist in nature and are catalytically active toward water splitting such as Ni₃N,¹² Ni₃Se₂,¹³ and Ni₃C.¹⁴ Furthermore, there have been no studies, experimental or theoretical, that investigate the effect of surface doping on the HER activity of Ni₂P, as most studies have considered bulk doping. Here, we study the influence of surface nonmetal doping on the surface structure, charge states, and HER activity of Ni₂P(0001) using density functional theory (DFT) calculations. We find that the Ni-Ni bond length is a robust descriptor for the HER activity of Ni₂P(0001) using

machine learning based on regularized random forests.¹⁵ This paper outlines a transferable approach for the use of machine learning to extract descriptors from DFT structural and charge data.

Methods

First-Principles Calculations

Spin-polarized DFT calculations were performed using the Quantum Espresso code (version 5.1). ¹⁶ Optimized, norm-conserving, designed nonlocal pseudopotentials were used to replace the nuclear Coulomb potential plus core electrons with a smoother, effective potential. ^{17,18} The valence electron wavefunctions were expanded in a plane-wave basis with an energy cutoff of 50 Ry. The generalized gradient approximation (GGA) of Perdew, Burke, and Ernzerhof (PBE)¹⁹ was used to calculate the exchange-correlation energy. Grimme's semiempirical DFT-D2 method ^{20,21} was used to include dispersion interactions, which are generally important for accurately modeling catalytic processes. ^{22,23} We choose the DFT-D2 method because it shows excellent agreement with higher-level electron correlation methods, *i.e.* Møller-Plesset perturbation theory (MP2) and coupled-cluster singles and doubles (CCSD), for H adsorption energies. ^{24,25}

We modeled the HER on an eight-layer, periodic slab of Ni₂P. The dimensions of the slab were a=b=10.07 Å and c=39.57 Å, and $\alpha=\beta=90^{\circ}$ and $\gamma=120.08^{\circ}$. The width of the vacuum region was 26.24 Å. A $(\sqrt{3} \times \sqrt{3})R30^{\circ}$ surface supercell was used so that we could model fractional surface concentrations of nonmetal dopants. A Γ -centered, $3\times 3\times 1$ grid of k-points was used to sample the Brillouin zone. During geometry relaxations, the bottom four layers of the slab were fixed in their bulk configurations.

Machine Learning

Regularized random forests (RRFs) were trained using the caret package (version 6.0.77) for R (version 3.2.5). ²⁶ Processed data and R scripts for the machine learning can be found in the Supporting Information. Three-fold cross-validation (CV) was performed to improve our prediction of the "out-of-sample" error. At each step of the training process, 10 descriptors were randomly selected and a regularization value of 0.1 and an importance coefficient of 0.75 were applied. More details on the DFT calculations and machine learning can be found in the Supporting Information.

Results and Discussion

Surface Structure and Doping Scheme

Bulk Ni₂P(s) has two alternating layers along the [0001] axis with compositions of Ni₃P and Ni₃P₂. Figure 1A shows the structure of the Ni₃P₂(0001) termination. The surface has one Ni₃-hollow site per unit cell (three per $\sqrt{3} \times \sqrt{3}R30^{\circ}$ supercell). In an aqueous

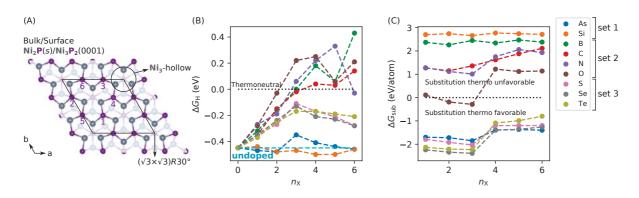


Figure 1: (A) Structure of Ni₃P₂(0001) surface of Ni₂P showing the $(\sqrt{3} \times \sqrt{3})R30^{\circ}$ supercell. The Ni₃-hollow sites, which bind H, are shown. The indices on P atoms indicate the preferred sequence of substitution with dopants. Free energy of (B) H adsorption and (C) dopant substitution as a function of the surface dopant concentration. $\Delta G_{\rm H} = 0$ is referred to as "thermoneutral" H adsorption. $\Delta G_{\rm H}$ for the undoped surface is labeled and denoted by a dashed, light blue line. The spontaneity of dopant substitution is labeled and indicated by a dotted black line.

electrochemical environment at U=0 V vs. SHE and pH=0, each Ni₃-hollow site binds H strongly ($\Delta G_{\rm H}=-0.45$ eV, $n_{\rm X}=0$ in Figure 1B). Each Ni bonds with two P in the surface layer and one P in the subsurface layer. This makes for a total of six symmetry-equivalent P atoms surrounding the Ni₃-hollow site in the surface layer, which are numbered from 1 through 6 in Figure 1A. We replace these surface P sites with nine different nonmetals (As, B, C, N, O, S, Se, Si, and Te) and varied the number of dopants ($n_{\rm X}$) from 1 to 6. We found that the S dopants prefer being separated at $n_{\rm S}=2$, i.e. S at positions 1 and 2 is more favorable than when they are sharing a common Ni (at positions 1 and 5) by 0.34 eV. Thus, for other dopants, and at higher doping concentrations, the maximum separation between dopants is maintained. The indices on P in Figure 1A correspond to the preferred sequence of substitution of the P atoms. For example, at $n_{\rm X}=3$, dopants are substituted at sites 1, 2, and 3. While the Ni and P sites are symmetrically-equivalent initially, doping breaks this symmetry.

Effect of Doping Concentration on H Adsorption and Dopant Substitution

H Adsorption

The effect of surface dopant identity and concentration on $\Delta G_{\rm H}$ at the Ni₃-hollow site is shown in Figure 1B. We observe three distinct trends corresponding to (1) As and Si, (2) 2p nonmetals (B, C, N, and O), and (3) chalcogenides (S, Se, and Te). The first set does not differ appreciably from the undoped surface (dashed, light blue line marked "undoped"). $\Delta G_{\rm H}$ is relatively constant with respect to changes in the surface dopant concentration. Conversely, 2p nonmetals (set 2) have a dramatic effect on $\Delta G_{\rm H}$, which generally increases with increasing $n_{\rm X}$. Nearly thermoneutral H adsorption is possible for $n_{\rm X}=2-3$ (50% substitution) and, above that, H adsorption is no longer favored. The chalcogenides (set 3), on the other hand, have an intermediate effect on $\Delta G_{\rm H}$. From $n_{\rm X}=1$ to 3, $\Delta G_{\rm H}$ increases

at about the same rate for each chalcogenide. From $n_{\rm X}=4$ to 6, however, $\Delta G_{\rm H}$ decreases, with the attenuation being more pronounced for S and Se than Te. The maximum $\Delta G_{\rm H}$ achieved is -0.11 eV for S at $n_{\rm X}=3$. Therefore, doping the Ni₃P₂(0001) surface of Ni₂P with 2p nonmetals (B, C, and O) or chalcogens at $\approx 50\%$ ($n_{\rm X}\approx 3$) can substantially improve the HER activity of the Ni₃-hollow site.

Dopant Substitution

Next, we evaluate the stability of different doping configurations. To do this, we calculate the free energy of substitution (ΔG_{sub}) relative to the computationally favorable phases under reducing conditions U = 0 V vs. SHE and pH = 0 of P and each dopant $(H_3PO_4, PO_4, PO_5, PO_5,$ As, SiO₂, H₃BO₃, CH₄, NH₄⁺, H₂O, H₂S, H₂Se, and Te)²⁷ for $n_{\rm X}=1$ to 6. Details and an example calculation of ΔG_{sub} for can be found in the Supporting Information (see Table S2). Figure 1C shows that ΔG_{sub} does not depend strongly on n_{X} ; however, a slight increase is observed for As, the chalcogens, C, N, and O. Substitution is exergonic for only five of the nine nonmetals: As, O, and the chalcogens. The others, period two nonmetals and Si, are significantly endergonic. The only set of nonmetals that both enhances the HER activity of the Ni₃-hollow site and stabilizes the surfaces is the chalcogens. O is an exception in set 2 as it substitutes spontaneously with P at $n_X = 2$ and 3. This has a negative effect on catalysis because at $n_{\rm X}=3$, where O substitution is most favorable, $\Delta G_{\rm H}=0.22$ eV, which is too weak for facile hydrogen evolution. However, since $\Delta G_{\rm sub}$ for the heavier chalcogens are much more favorable, substitution with S, Se, and Te will be able to inhibit the introduction of O in the surface. Such substitutions can thus suppress catalytically degenerative oxygenation of the surface, highlighting another advantage of nonmetal doping. As such, we propose surface doping with S, Se, and Te as a very promising route for improving the HER activity of $Ni_3P_2(0001)$.

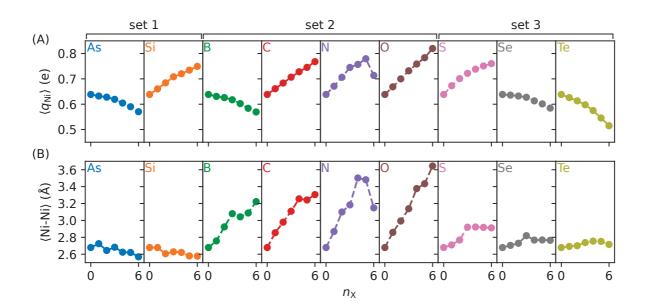


Figure 2: Effect of dopant and surface concentration on the (A) average Ni residual charge $(\langle q_{\text{Ni}} \rangle)$ and (B) average Ni-Ni bond length $(\langle \text{Ni-Ni} \rangle)$.

Exploratory Data Analysis

Charge Descriptors

In order to better understand the trends in $\Delta G_{\rm H}$ and $\Delta G_{\rm sub}$ with respect to $n_{\rm X}$, we first perform a rudimentary exploratory analysis of charge descriptors. Figure 2A shows nearly linear trends between the average Ni residual charge ($\langle q_{\rm Ni} \rangle$) and number of dopants ($n_{\rm X}$). Their slopes can be interpreted as the direction of electron transfer between Ni and the dopant. For example, positive slopes correspond to electron transfer from Ni to the dopant, thereby oxidizing Ni (the electron donor) and reducing the nonmetal (the electron acceptor). The opposite is true for negative slopes. $\langle q_{\rm Ni} \rangle$ does not correlate strongly with $\Delta G_{\rm H}$. For example, S and Se have very similar trends in $\Delta G_{\rm H}$ (see Figure 1B). However, S and Se cause opposite shifts in $\langle q_{\rm Ni} \rangle$. Additionally, there are no significant changes in their $\langle q_{\rm Ni} \rangle$ trends that coincide with the maximum in $\Delta G_{\rm H}$ at $n_{\rm X}=3$. Therefore, $\langle q_{\rm Ni} \rangle$ is a poor descriptor of $\Delta G_{\rm H}$.

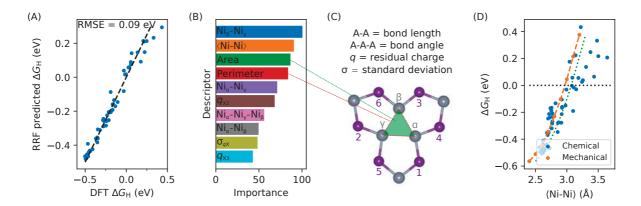


Figure 3: (A) $\Delta G_{\rm H}$ predicted by RRFs vs. DFT. Black-dashed line corresponds to perfect agreement. (B) Relative importance of descriptors calculated from RRF model. Only the top 10 features are shown (see Figure S2 in the Supporting Information for full list). (C) Definition of descriptors in (B). We label the three Ni atoms α , β , and γ based on their distance from the first doping site. (D) Effect of average Ni-Ni bond length on $\Delta G_{\rm H}$ as induced by chemical pressure and mechanical pressure. Chemical pressure was induced by surface nonmetal doping and mechanical pressure by fixing the positions of surface Ni atoms. Green dotted line adjusts for Ni-Ni bond contraction upon H adsorption in the mechanical case. According to the mechanical pressure calculations, the ideal Ni-Ni bond length for HER is between 2.97 and 3.07 Å.

Important Descriptors from Machine Learning

In order to rationalize the trends in $\Delta G_{\rm H}$, we search for other structural and charge descriptors. For each DFT-relaxed structure, we compile Ni-Ni bond lengths, Ni-Ni-Ni bond angles, Löwdin charges, elemental data (mass number, atomic weight, and atomic radius), summary statistics (mean and standard deviation), and other geometric parameters (perimeter and area of Ni₃-hollow sites). Note that the descriptors we chose involve only the H adsorption site, *i.e.* the Ni₃-hollow site, and the dopants. Descriptors involving surface P atoms are deemed unnecessary because they don't directly participate in bonding, and changes in the Ni-P bond lengths are in fact already included in the contraction or expansion of the Ni₃-hollow sites. Removing such potentially redundant descriptors keeps the data simple. Our data are obtained from surfaces without H, because we want to be able to predict HER activity based on intrinsic surface properties. In total, the data set has 55 observations (structures) and 30 variables (29 descriptors and $\Delta G_{\rm H}$). Machine learning is becoming increasingly

popular for semi-automated and quantitative discovery of data correlations in chemistry and materials science. ^{28–30} Using these data, we trained an RRF, yielding a root-mean-squared error (RMSE) of 0.09 eV. Figure 3A shows that the data very closely straddle the perfect correlation line. Note that we performed three-fold CV instead of randomly splitting the data into one training and one test set (see Figure S1 in the Supporting Information). In general, k-fold CV splits the data into k sets and averages the models generated by training on k-1 of the sets and testing on the other. This method gives better estimates of the "out-of-sample" error, which in our case refers to the RMSE in the prediction of $\Delta G_{\rm H}$, than randomly train/test splitting.

The architecture of RRFs allows for the calculation of feature importances. These measure the relative importance of different descriptors in describing the HER activity of nonmetal-doped Ni₂P(0001) surfaces. Importance is defined as the normalized ability of a descriptor to separate the data based on $\Delta G_{\rm H}$. Figure 3B shows the top ten, most important descriptors from the 29 included in our data set. The top two descriptors are a particular Ni-Ni bond length (whose constituent atoms are distinguished by their distance from the first doping site, see Figure 3C) and the average Ni-Ni bond length ($\langle Ni-Ni \rangle$). Of the top ten descriptors, seven are related to the geometry of the Ni₃-hollow site. Other important features include the charges of dopants at $n_{\rm X}=2$ and 3 ($q_{\rm X2}$ and $q_{\rm X3}$), and the standard deviation of the dopant charges (σ_{qX}) . While in principle, it would be straightforward to include more complex descriptors like the electronic DOS and its moments (e.g. the d-band center ^{31,32} of Ni), this is shown to be unnecessary, however, because the simple and intuitive Ni-Ni bond length proves to be quite descriptive of HER activity. Further, the fact that the atomic charges exhibit poor correlation indicates that such metrics that depend on electronic partitioning will also likely be unimportant.

Structural Descriptors

Having identified (Ni-Ni) as a good descriptor for $\Delta G_{\rm H}$, we more closely examine their correlation. Figure 2B shows the effect of surface doping on $\langle Ni-Ni \rangle$ as a function of n_X . Like $\Delta G_{\rm H}$, (Ni-Ni) is relatively unaffected by doping with As and Si. The period two nonmetals, however, induce a significant expansion in the (Ni-Ni). This correlates quite strongly (Pearson's $r \ge 0.41$, r = -1 or 1 for perfect negative and positive correlation, respectively) with $\Delta G_{\rm H}$, which also increases dramatically with increasing $n_{\rm X}$. The chalcogens (set 3) show two regimes of change in $\langle Ni-Ni \rangle$, much like their trends for $\Delta G_{\rm H}$ and $\Delta G_{\rm sub}$. For set 3, at lower surface doping concentrations (i.e. $n_{\rm X}=1$ to 3), the $\langle {\rm Ni-Ni} \rangle$ increases with the increase for S being largest and Te the smallest. At higher surface doping concentrations (i.e. $n_{\rm X}=4$ to 6), (Ni-Ni) plateaus. While there is an apparent moderate dependence of $\Delta G_{\rm H}$ or $\langle Ni-Ni \rangle$ on n_X seen in Figures 1B and 2B, it only became evident that Ni-Ni bond lengths are good descriptors for HER activity through the training of the RRF model. Since the influence of surface nonmetal doping on both the geometry of the Ni₃-hollow site and $\Delta G_{\rm H}$ are similar, this implies a chemical pressure-like effect 33 that can be summarized as follows. Nonmetal surface doping effectively acts like mechanical pressure, expanding or compressing the Ni₃-hollow site.

This effect can be rationalized as follows. As the Ni₃-hollow site expands, the Ni-H bonds that form will have to stretch if H is to remain at the center. Upon sufficient expansion, however, H must reduce/sever its interaction with one or two Ni atoms to form an optimal Ni-H bond length, thereby weakening its adsorption strength (see Figure S3 in the Supporting Information for an example of this). The HER can be broken down into two steps, H adsorption and H₂ desorption. The former is called the Volmer reaction, and its rate is proportional to the strength of H adsorption. H₂ desorption can follow either the Tafel or Heyrovsky mechanism. The rates for both of these reactions are inversely proportional to the strength of H adsorption. In order to maximize the rate of the HER, a compromise, often called the Sabatier principle, ³⁴ must be made between H adsorption and H₂ desorption. This

compromise is struck at $\Delta G_{\rm H}=0$, which is referred to as thermoneutral H adsorption. As a final comment, the Brønsted-Evans-Polanyi (BEP) principle states that there is a linear relationship between the kinetic barrier and the free energy of a reaction. Therefore, by weakening H adsorption at the Ni₃-hollow site via dopant-induced tensile strain, the kinetic barrier for HER is also decreased and its rate is increased.

Local charges play a minimal role because the surface is metallic³⁵ and therefore can easily provide the requisite free charge to stabilize adsorption. The effect of doping on the surface strain is nonlinear with the dopant atomic radius because the induced strain is a complex function of the relative electronegativity of the constituent atoms, valence, concentrations of the dopants, and coordination chemistry. Naturally, dopants that form shorter Ni-X bonds will expand the Ni₃-hollow site, while those that form longer Ni-X bonds will cause the Ni₃-hollow site to contract. This explains the more drastic effect of 2p nonmetals on the adsorption of H due to the Ni₃-hollow site's expansion. However, the mechanical effect of X on Ni-X bonding is also dependent on the dopant concentration, hence the observed nonlinear dependence of $\langle Ni - Ni \rangle$ on n_X (Figure 2B). These explain why the dopant atomic radius appears to be a less important descriptor for $\Delta G_{\rm H}$.

Chemical Pressure Proof of Concept

In order to confirm this machine learning insight, we apply mechanical pressure to the Ni₃-hollow site. The $\langle \text{Ni-Ni} \rangle$ was compressed and expanded by fixing the internal coordinates of the surface Ni atoms and allowing the other surface atoms to relax during DFT geometry optimization. Note that the lattice constants were fixed. Figure 3D shows that applied mechanical pressure (orange points and dashed line) induces the same change in $\Delta G_{\rm H}$ as does chemical pressure via nonmetal doping (blue points). Therefore, it is not the electronic character of the nonmetal dopants but rather the structural distortion they induce on the surface that modulates the HER activity of the Ni₃P₂(0001) surface. Note that our calculations indicate that $\langle \text{Ni-Ni} \rangle$ contracts by ≈ 0.1 Å upon H adsorption. This means that since

the internal coordinates of Ni are fixed even upon H adsorption, unlike in the doping case, we are likely overestimating $\Delta G_{\rm H}$, and thus the orange line represents an upper limit for the mechanical pressure effect. If we manually adjust $\langle \text{Ni-Ni} \rangle$ by 0.1 Å (Fig. 3D green dotted line), the agreement between mechanical and chemical pressure improves.

Perspectives

Based on the mechanical pressure calculations, $\langle \text{Ni-Ni} \rangle \approx 2.97 - 3.07$ Å should produce thermoneutral H adsorption and thus the optimal intrinsic activity for an HER electrocatalyst expressing the Ni₃ motif. The optimal bond length should be used in high-throughput searches to screen for bulk binary Ni-nonmetal compounds. An alternative would be to study mixed nonmetal doping, e.g. doping with both S and Se. We anticipate that undoped and doped transition metal phosphides with bulk crystal structures similar to Ni₂P(s), such as Fe₂P(s), Co₂P(s), (Fe,Co)P(s), and (Ni,Co)P(s), will also exhibit chemical pressure-driven enhancement of HER to varying degrees. Our study demonstrates that a comprehensive investigation of surface nonmetal doping for a variety of single and mixed transition metal phosphides will reveal promising candidate materials with nearly ideal intrinsic activity toward the HER.

In these kinds of doping studies, we should not lose sight of the thermodynamics and kinetics of dopant incorporation and segregation within the bulk, as this will provide valuable information regarding the feasibility of synthesizing catalysts. We have shown that certain dopants may stabilize the surface with respect to dissolution, e.g. doping with chalcogens or As.

Our current data set for machine learning is specifically obtained for the Ni₂P surface that expresses the Ni₃ motif, and thus the method will work best in predicting perturbations within the structural framework of Ni₂P. A great example of extending this model would be the examination of doping with transition metals, as mentioned above, in cases where this only causes minimal changes to the underlying atomic structure of Ni₂P. A model that is

transferable across different bulk transition-metal phosphides would of course require additional structure-specific inputs during training. Although the RRF is trained using only a subset of dopant arrangements, having verified the predictive power of Ni₃-structure-based descriptors, the RRF model should also be able to predict the $\Delta G_{\rm H}$ of other dopant configurations with high precision and accuracy.

Unlike $\langle \text{Ni-Ni} \rangle$, $\langle q_{\text{Ni}} \rangle$ does not correlate strongly with ΔG_{H} . Even though the nonmetal dopants substitute at spectator sites, it is contrary to common understanding of dopant effects that their electronic structure does not play a large role in determining HER activity. This could be explained by the fact that $Ni_2P(s)$ is metallic and therefore charge partitioning between the Ni and nonmetal components is less well defined. This hypothesis is corroborated by the results in Figure 2A, which show that the average charge on Ni only changes by a small fraction of the charge of an electron from low to high surface doping concentrations. The structural parameters of the Ni₃-hollow site are more sensitive to changes in the surface electronic structure and therefore they are able to more accurately capture the trends between $n_{\rm X}$ and $\Delta G_{\rm H}$. This lends further support to our claim that chemical pressure is the key driving force behind the enhanced HER activity of doped $Ni_3P_2(0001)$. The connection between strain and catalytic activity has been explored in the literature, especially with regard to substrate-induced ^{36,37} and electrochemically-induced ³⁸ strain. For example, compressive strain was demonstrated to enhance the oxygen reduction reaction on dealloyed Pt-Cu and Pt nanoparticles via enhancement of the binding of intermediate oxygenated adsorbates, ^{37,38} while tensile strain was shown to stabilize CO and O chemisorption and CO dissociation on Ru(0001).³⁶ Here, expansion of the Ni₃ site (local, chemically-induced tensile strain) reduces the affinity of H due to the reduced H coordination. The most promising catalytic system that we discovered was chalcogen-doped $Ni_3P_2(0001)$. For S $(n_S = 3)$, the HER overpotential is -0.11 V vs. SHE. This is much lower than that of the Ni₃-hollow site in the absence of dopants (-0.45 V vs. SHE). This overpotential is similar to that of the P-enriched, nonstoichiometric reconstruction (-0.07 V vs. SHE) but this surface is only accessible upon applying -0.21 V vs. SHE.⁵

Conclusions

In summary, we have demonstrated that surface nonmetal doping can significantly improve the HER activity of Ni₂P. We find that the Ni-Ni bond length is an effective descriptor for the HER activity of Ni₃P₂(0001) of Ni₂P and hence can be used in a computationally efficient, high-throughput search to screen for promising Ni-nonmetal catalytic materials. We have shown how machine learning methodologies can be implemented in the catalyst design pipeline to automatically discover and rank the importance of structural and chargebased descriptors for HER. Machine learning is highly customizable in that many different model types can be selected (here we choose RRFs) and the number and types of descriptors is limited only by scientific creativity. We validated the results from our machine learning by applying mechanical pressure to compress and expand the Ni_3 -hollow sites, which showed that the effects of chemical pressure via nonmetal doping and mechanical pressure are in excellent agreement. Our results strongly indicate that it is the induced local geometry of the Ni₃-hollow site and not the electronic character of the dopants that improves the HER activity of $Ni_3P_2(0001)$. We believe that this insight should spur both experimental and theoretical research in surface nonmetal doping of transition metal phosphides in the wider effort find ideal HER catalysts.

Acknowledgement

R.B.W., J.M.P.M., and A.M.R. acknowledge support from the Office of Naval Research under grant number N00014-17-1-2574. The authors also acknowledge computational support from the High-Performance Computing Modernization Office and the National Energy Research Scientific Computing Center.

Supporting Information Available

Additional computational details, additional theoretical details, tabulated standard oxidation/reduction free energy of nonmetal standard states to form most stable phases, tabulated free energy of substituting P with other nonmetals relative to their standard states, the relative importance of all descriptors calculated from the RRF model, and sample illustrations of the effect of Ni₃-hollow site expansion induced by doping with nonmetals on the strength of Ni-H bonds.

References

- (1) Hinnemann, B.; Moses, P. G.; Bonde, J.; Jørgensen, K. P.; Nielsen, J. H.; Horch, S.; Chorkendorff, I.; Nørskov, J. K. J. Am. Chem. Soc. 2005, 127, 5308–5309.
- (2) Jaramillo, T. F.; Jørgensen, K. P.; Bonde, J.; Nielsen, J. H.; Horch, S.; Chorkendorff, I. Science 2007, 317, 100–102.
- (3) Liu, P.; Rodriguez, J. A. J. Am. Chem. Soc. 2005, 127, 14871–14878.
- (4) Popczun, E. J.; McKone, J. R.; Read, C. G.; Biacchi, A. J.; Wiltrout, A. M.; Lewis, N. S.; Schaak, R. E. J. Am. Chem. Soc. 2013, 135, 9267–9270.
- (5) Wexler, R. B.; Martirez, J. M. P.; Rappe, A. M. ACS Catal. 2017, 7, 7718–7725.
- (6) Liang, H.; Gandi, A. N.; Anjum, D. H.; Wang, X.; Schwingenschlögl, U.; Alshareef, H. N. Nano Lett 2016, 16, 7718–7725.
- (7) Feng, Y.; Yu, X.-Y.; Paik, U. ChemComm **2016**, 52, 1633–1636.
- (8) Li, J.; Yan, M.; Zhou, X.; Huang, Z.-Q.; Xia, Z.; Chang, C.-R.; Ma, Y.; Qu, Y. Adv. Funct. Mater. **2016**, 26, 6785–6796.

- (9) Wang, P.; Pu, Z.; Li, Y.; Wu, L.; Tu, Z.; Jiang, M.; Kou, Z.; Amiinu, I. S.; Mu, S. *ACS Appl. Mater. Interfaces* **2017**, *9*, 26001–26007.
- (10) Zhang, Y.; Liu, Y.; Ma, M.; Ren, X.; Liu, Z.; Du, G.; Asiri, A. M.; Sun, X. *ChemComm* **2017**, *53*, 11048–11051.
- (11) Sun, Y.; Hang, L.; Shen, Q.; Zhang, T.; Li, H.; Zhang, X.; Lyu, X.; Li, Y. *Nanoscale* **2017**, *9*, 16674–16679.
- (12) Shalom, M.; Ressnig, D.; Yang, X.; Clavel, G.; Fellinger, T. P.; Antonietti, M. *J. Mater. Chem. A* **2015**, *3*, 8171–8177.
- (13) Swesi, A. T.; Masud, J.; Nath, M. Energy Environ. Sci. 2016, 9, 1771–1782.
- (14) Yang, W.; Rehman, S.; Chu, X.; Hou, Y.; Gao, S. ChemNanoMat 2015, 1, 376–398.
- (15) Deng, H.; Runger, G. Pattern Recognit. 2013, 46, 3483–3489.
- (16) Giannozzi, P.; Baroni, S.; Bonini, N.; Calandra, M.; Car, R.; Cavazzoni, C.; Ceresoli, D.; Chiarotti, G. L.; Cocccioni, M.; Dabo, I.; Corso, A. D.; de Gironcoli, S.; Fabris, S.; Fratesi, G.; Gebauer, R.; Gerstmann, U.; Gougoussis, C.; Kokalj, A.; Lazzeri, M.; Martin-Samos, L.; Marzari, N.; Mauri, F.; Mazzarello, R.; Paolini, S.; Pasquarello, A.; Paulatto, L.; Sbraccia, C.; Scandolo, S.; Sclauzero, G.; Seitsonen, A. P.; Smogunov, A.; Umari, P.; Wentzcovitch, R. M. J. Phys.: Condens. Matter 2009, 21, 395502 (1–19).
- (17) Rappe, A. M.; Rabe, K. M.; Kaxiras, E.; Joannopoulos, J. D. Phys. Rev. B Rapid Comm. 1990, 41, 1227–1230.
- (18) Ramer, N. J.; Rappe, A. M. Phys. Rev. B 1999, 59, 12471–12478.
- (19) Perdew, J. P.; Burke, K.; Ernzerhof, M. Phys. Rev. Lett. 1996, 77, 3865 (1–8).
- (20) Grimme, S. J. Comput. Chem. 2006, 27, 1787–1799.

- (21) Barone, V.; Casarin, M.; Forrer, D.; Pavone, M.; Sambi, M.; Vittadini, A. *J. Comput. Chem.* **2009**, *30*, 934–939.
- (22) Ramalho, J. P. P.; Gomes, J. R.; Illas, F. RSC Adv. 2013, 3, 13085–13100.
- (23) Eder, F.; Lercher, J. A. Zeolites 1997, 18, 75–81.
- (24) Zhou, Z.; Zhao, J.; Chen, Z.; Gao, X.; Yan, T.; Wen, B.; Schleyer, P. v. R. *J. Phys. Chem. B* **2006**, *110*, 13363–13369.
- (25) Krishnan, S.; Vadapoo, R.; Riley, K. E.; Velev, J. P. *Phys. Rev. B* **2011**, *84*, 165408 (1–6).
- (26) Kuhn, M. J. Stat. Softw. 2008, 28, 1–26.
- (27) Jain, A.; Ong, S. P.; Hautier, G.; Chen, W.; Richards, W. D.; Dacek, S.; Cholia, S.; Gunter, D.; Skinner, D.; Ceder, G.; Persson, K. a. APL Mater. 2013, 1, 011002.
- (28) Saal, J. E.; Kirklin, S.; Aykol, M.; Meredig, B.; Wolverton, C. *JOM* **2013**, *65*, 1501–1509.
- (29) Ivanciuc, O. Reviews in Computational Chemistry 2007, 23, 291–400.
- (30) Handley, C. M.; Popelier, P. L. J. Phys. Chem. A **2010**, 114, 3371–3383.
- (31) Nørskov, J. Prog. Surf. Sci. 1991, 38, 103–144.
- (32) Hammer, B.; Norskov, J. Nature **1995**, 376, 238–240.
- (33) Raaen, S.; Parks, R. Solid State Commun. 1983, 48, 199–202.
- (34) Sabatier, P. La Catalyse en Chimie Organique; Berague: Paris, France, 1920.
- (35) Wexler, R. B.; Martirez, J. M. P.; Rappe, A. M. Chem. Mater. 2016, 28, 5365–5372.
- (36) Mavrikakis, M.; Hammer, B.; Nørskov, J. K. Phys. Rev. Lett. 1998, 81, 2819–22.

- (37) Strasser, P.; Koh, S.; Anniyev, T.; Greeley, J.; More, K.; Yu, C.; Liu, Z.; Kaya, S.; Nordlund, D.; Ogasawara, H. *Nat. Chem.* **2010**, *2*, 454–460.
- (38) Wang, H.; Xu, S.; Tsai, C.; Li, Y.; Liu, C.; Zhao, J.; Liu, Y.; Yuan, H.; Abild-Pedersen, F.; Prinz, F. B. *Science* **2016**, *354*, 1031–1036.

TOC Graphic

